

**REMARKS**

This Amendment amends claim 14 in response to the Notice of Non-Compliant Amendment dated May 7, 2002. Claims 1-22 are pending. Claims 1-12 have been withdrawn from prosecution. Of the remaining claim, claim 14 is independent.

Attached hereto is a marked-up version of the changes made to the claim by the current Amendment. The attached page is captioned "**VERSIONS WITH MARKINGS TO SHOW CHANGES MADE**".

**III. FORMAL MATTERS AND CONCLUSION**

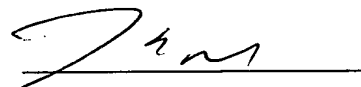
In view of the foregoing amendments and remarks, Applicants respectfully submit that the Application is in condition for allowance. Applicants respectfully request prompt reconsideration and allowance.

Should the Examiner believe that anything further is desirable to place the application into condition for allowance, Applicants invite the Examiner to contact the undersigned attorney at the telephone number listed below.

The Commissioner is hereby authorized to charge any deficiency in fees or to credit any overpayment in fees to Attorney's Deposit Account No. 50-0481.

Respectfully Submitted,

Date: 5/13/02



James E. Howard  
Reg. No. 39,715

**McGinn & Gibb, PLLC**  
8321 Old Courthouse Rd., Suite 200  
Vienna, Virginia 22182  
(703) 761-4100  
**Customer No. 21254**

**VERSION WITH MARKINGS TO SHOW CHANGES MADE**

**In the claims:**

**Please amend claim 14 as follows:**

14. (Amended) A method for producing a transparent laminate comprising [steps of]:  
preparing a transparent substrate;  
depositing a high-refractive-index transparent thin film by a vacuum dry process;  
depositing a silver transparent conductive thin film by a vacuum dry process;  
repeating [said steps for] forming of the high-refractive-index transparent thin film  
and the silver transparent conductive thin film at least three [or four] times to thereby form at  
least three [or four] combination thin-film layers of the high-refractive-index transparent thin  
film and the silver transparent conductive thin film successively laminated on a surface of  
said transparent substrate; and  
depositing another high-refractive-index transparent thin film on a surface of said  
combination thin-film layer by the vacuum dry process,  
wherein, when said silver transparent conductive thin films are deposited by the  
vacuum dry process, temperature  $T$  (K) of said transparent substrate at the time of the  
deposition of said films is set to be in a range  $340 \leq T \leq 390$ , and deposition rate  $R$  (nm/sec) of  
said silver transparent conductive thin films is set to be  $R = (1/40) \times (T - 300) \pm 0.5$ .